



SHOT BY

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On Tuesday night, Epson, the global leader in printing and imaging technology, kicked off New York Fashion Week with its second installment of the “Epson Digital Couture Fashion Presentation.” A unique group of 11 specially selected designers from the Americas showcased collections reflecting a theme of “Peace and Harmony through Fashion,” by displaying Epson’s state of the art direct-to-garment digital dye sublimation printing.

A-listers including Abby Elliott, Arden Wohl, Chloe Norgaard, Harley-Viera Newton, Langley Fox and Selita Ebanks were on hand to lend their support, while super DJ Chelsea Leyland and Pamela Katz rocked the DJ booth. Guests enjoyed cocktails from Svedka, Maven Cocktails, VOGA, DRY Sparkling, Rekorderlig Cider, SERPENT’S BITE and American Juice Company.

The emerging young designers showcased were Agostina Orlandi and Ludmila Osikovsky from Argentina, Fabio Yukio from Brazil, Cristina Ruales from Brooklyn, NY, Matías Hernán from Chile, Felipe Santamaría Luque from Colombia, Fabrizzio Berrocal from Costa Rica, Gustavo Moscoso from Ecuador, Chloe Trujillo from Los Angeles, CA, María de Lourdes Ramírez and Isabel Navarro Landa from Mexico, Danny Santiago from Miami, FL, and Janet Ríos and Carmen Artica from Peru. Stop Embassy Management’s Luis Casco for Mary Kay, Dr’s REMEDY & Maxus Nails, and Edison Lu & Hair Lounge were on hand to provide makeup, nails and hair for the presentation